



Form PTO-1449 (modified)

List of Patents and Publications for Applicant

INFORMATION DISCLOSURE STATEMENT

(Use several sheets if necessary)

Atty. Docket No.
2000.109700/DE0351Serial No.
10/747,722Applicant
Axel Preusse, Markus Nopper and Holger SchuhrerFiling Date:
December 29, 2003Group:
2811U.S. Patent Documents
See Page 1Foreign Patent Documents
See Page 1Other Art
See Page 1

U.S. Patent Documents

Exam. Init.	Ref. Des.	Document Number	Date	Name	Class	Sub Class	Filing Date of App.
EP	A1	5,091,047	2/25/92	Cleaves <i>et al.</i>	156	643	
	A2	5,340,435	8/23/94	Ito <i>et al.</i>	156	632	
	A3	5,966,628	10/12/99	Wei <i>et al.</i>	438	584	
EP	A4	6,150,696	11/21/00	Iwamatsu <i>et al.</i>	257	347	
	A5						

Foreign Patent Documents

Exam. Init.	Ref. Des.	Document Number	Date	Country	Class	Sub Class	Translation Yes/No
	B1						
	B2						
	B3						

Other Art (Including Author, Title, Date Pertinent Pages, Etc.)

Exam. Init.	Ref. Des.	Citation
EP	C1	Wolf <i>et al.</i> , SILICON PROCESSING FOR THE VLSI ERA, Vol. 1: Process Technology, pp. 400-403 and 532-533, 1986
	C2	
	C3	

EXAMINER:

EP

DATE CONSIDERED:

10-25-04

EXAMINER: INITIAL IF REFERENCE CONSIDERED, WHETHER OR NOT CITATION IS IN CONFORMANCE WITH MPEP609; DRAW LINE THROUGH CITATION IF NOT IN CONFORMANCE AND NOT CONSIDERED. INCLUDE COPY OF THIS FORM WITH NEXT COMMUNICATION TO APPLICANT.